

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1 - 13 (canceled)

14 (currently amended): An extruded base for an imaging element comprising a matrix polymer and an intercalated clay comprising clay intercalated with polyether block polyamide copolymer, wherein said matrix polymer comprises polyolefin or polyester.

15 (canceled):

16 (previously presented): The extruded base of claim 14 wherein said matrix polymer comprises poly(propylene).

17 (canceled):

18 (currently amended): The extruded base of claim ~~14~~¹⁷ wherein said polyester comprises polyethylene terephthalate.

19 (currently amended): The extruded base of claim ~~14~~¹⁷ wherein said polyester comprises crystalline polyester.

20 (currently amended): The extruded base ~~article~~ of claim ~~14~~¹⁷ wherein said polyester comprises amorphous polyester.

21 (canceled):

22 (previously presented): The extruded base of claim 14 wherein said article further comprises compatibilizer.

23 (previously presented): The extruded base of claim 22 wherein said compatibilizer comprises polyolefins.

24 (previously presented): The extruded base of claim 14 wherein said article has a surface resistivity of less than 10^{13} ohms per square.

25 (previously presented): The extruded base of claim 24 wherein said surface resistivity is between 10^8 and 10^{12} ohms per square.

26 (previously presented): The extruded base of claim 14 wherein the Young's modulus of the said copolymer and matrix polymer is enhanced by at least 10%.

27 (previously presented): The extruded base of claim 14 wherein the Young's modulus of the said copolymer and matrix polymer is enhanced by at least 20%.

28 (previously presented): The extruded base of claim 27 wherein said matrix polymer comprises polyolefin and said polyolefin comprises between 20 and 99.9 % by weight of said article.

29 (previously presented): The extruded base of claim 14 wherein said clay comprises smectite clay.

30 (previously presented): The extruded base of claim 14 wherein said clay comprises synthetic smectite clay.

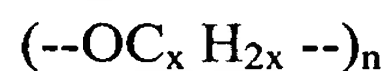
31 (previously presented): The extruded base of claim 14 wherein the ratio by weight of clay to copolymer is between 1:99 and 99:1.

32 (previously presented): The extruded base of claim 14 wherein the polyether to polyamide molecular weight ratio is between 5:95 and 95:5.

33 (previously presented): The extruded base of claim 14 wherein said copolymer comprises blocks selected from the group consisting of polyamide

6, polyamide 12, polyethylene oxide, polyethylene glycol, polytetramethylene oxide, and polytetramethylene glycol.

34 (previously presented): The extruded base of claim 33 wherein in said polyether block comprises a structure



wherein x is from 2 to about 8, wherein the alkyl group is straight or branched, and

wherein n is from 2 to about 1000.

35 (previously presented): The extruded base of claim 14 wherein said imaging member comprises a base for a photographic member.

36 (canceled):

37 (previously presented): An extruded base comprising polyether block polyamide copolymer and intercalated clay, wherein said article comprises a base for an imaging member.

38 (previously presented): The extruded base of claim 37 wherein said article has a surface resistivity of less than 10^{13} ohms per square.

39 (previously presented): The extruded base of claim 37 wherein the Young's modulus of the said copolymer is enhanced by at least 10%.

40 (previously presented): The extruded base of claim 37 wherein the Young's modulus of the said copolymer is enhanced by at least 20%.

41 (previously presented): The extruded base of claim 37 wherein said clay comprises smectite clay.

42 (previously presented): The extruded base of claim 37 wherein said clay comprises synthetic smectite clay.

43 (previously presented): The extruded base of claim 37 wherein the ratio by weight of clay to copolymer is between 1:99 and 99:1.

44 (previously presented): The extruded base of claim 37 wherein the polyether to polyamide molecular weight ratio is between 5:95 and 95:5.

45 (previously presented): The extruded base of claim 37 wherein said copolymer comprises blocks selected from the group consisting of polyamide 6, polyamide 12, polyethylene oxide, polyethylene glycol, polytetramethylene oxide, and polytetramethylene glycol.

46 (previously presented): The extruded base of claim 37 wherein said imaging member comprises a base for a photographic member.

47 (canceled):

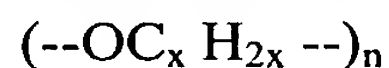
48 (canceled):

49 (previously presented): The extruded base of claim 14 wherein in said polyamide block comprises the recurring unit represented by the general formula:



wherein R^1 is an alkylene group of at least 2 carbon atoms or arylene having at least 6 carbon atoms; and
 R^2 is selected from R^1 and aryl groups.

50 (previously presented): The extruded base of claim 37 wherein in said polyether block comprises a structure



wherein x is from 2 to about 8, wherein the alkyl group is straight or branched, and wherein n is from 2 to about 1000.

51 (previously presented): The extruded base of claim 37 wherein in said polyamide block comprises the recurring unit represented by the general formula:



wherein R¹ is an alkylene group of at least 2 carbon atoms or arylene having at least 6 carbon atoms; and R² is selected from R¹ and aryl groups.

52 (canceled)

53 (canceled)